

Density functional study of carbon mono- and bilayers on SiC

by Constanze Jahn

Overview

- Motivation
- Density functional theory
- on SiC
 - properties
 - surface reconstructions
 - Production of SiC/Graphene
 - model interface
- Graphene
- Results of the calculations:
 - SiC (0001)/ Graphene
 - SiC (000-1)/ Graphene
- Outlook

Motivation

Motivation

„free standing graphene“
for electronic applications

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2D nano-electronics:



Motivation

„free standing graphene“
for electronic applications

2D nano-electronics:



Interface SiC/Graphene:

- atomic structure
- electronic structure

Density functional theory

after Hohenberg, Kohn and Sham

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wavefunction $\Psi\{ (r_i) \}$ \longrightarrow density $n(\mathbf{r})$

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Energy E \longrightarrow Functional $E[n(\mathbf{r})]$

Density functional theory

after Hohenberg, Kohn and Sham

wavefunction $\Psi\{ (r_i) \}$



density $n(\mathbf{r})$

Energy E



Functional $E[n(\mathbf{r})]$

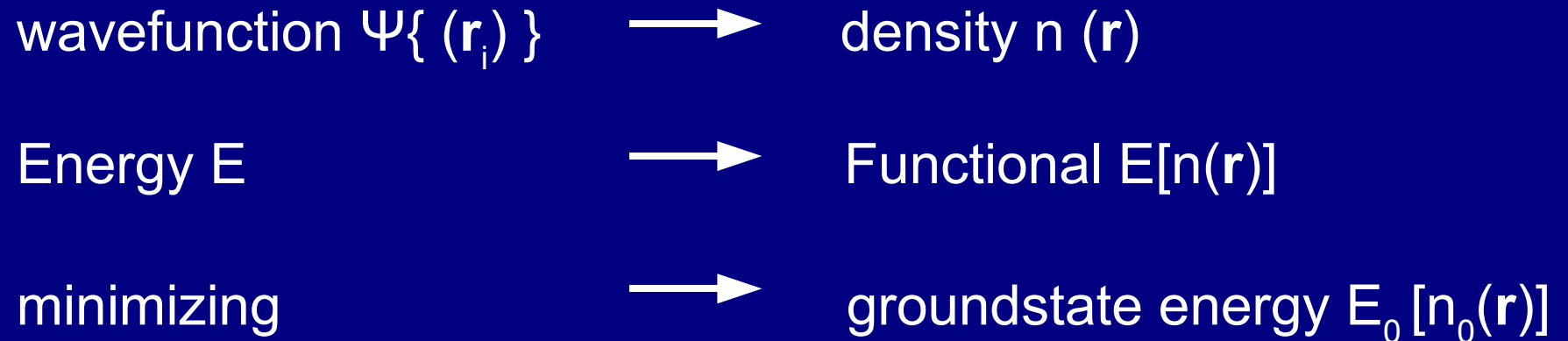
minimizing



groundstate energy $E_0[n_0(\mathbf{r})]$

Density functional theory

after Hohenberg, Kohn and Sham



Kohn-Sham-formalism:

effective one particle system $\Phi_i(\mathbf{r}) \rightarrow n_0(\mathbf{r}) = \sum_i |\Phi_i(\mathbf{r})|^2$

$$[-1/2 \Delta + V_H[n_0](\mathbf{r}) + V_{XC}[n_0](\mathbf{r}) + V_{el}(\mathbf{r}, \{\mathbf{R}_i\})] \Phi_i(\mathbf{r}) = \varepsilon_i \Phi_i(\mathbf{r})$$

Density functional theory

after Hohenberg, Kohn and Sham

wavefunction $\Psi\{ (r_i) \}$	\longrightarrow	density $n(\mathbf{r})$
Energy E	\longrightarrow	Functional $E[n(\mathbf{r})]$
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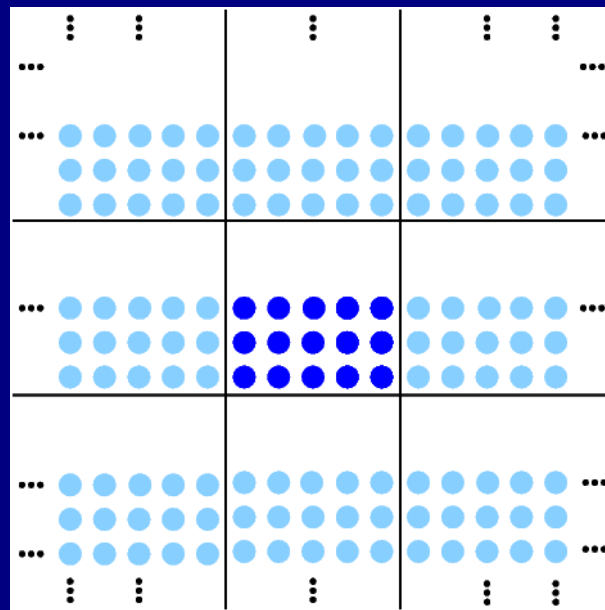
$V_{XC}[n_0](\mathbf{r})$ unknown: local density approximation (LDA)

Density functional theory

after Hohenberg, Kohn and Sham

- using software package VASP for calculations

Supercell:



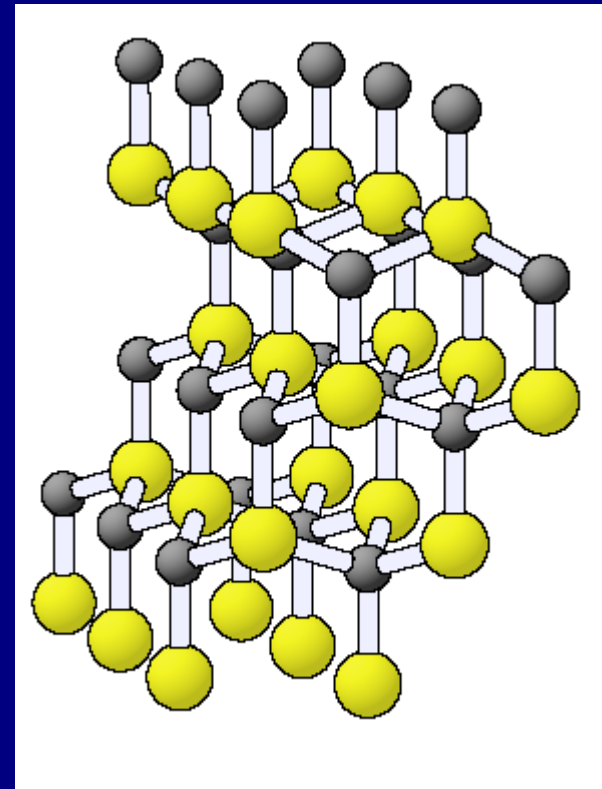
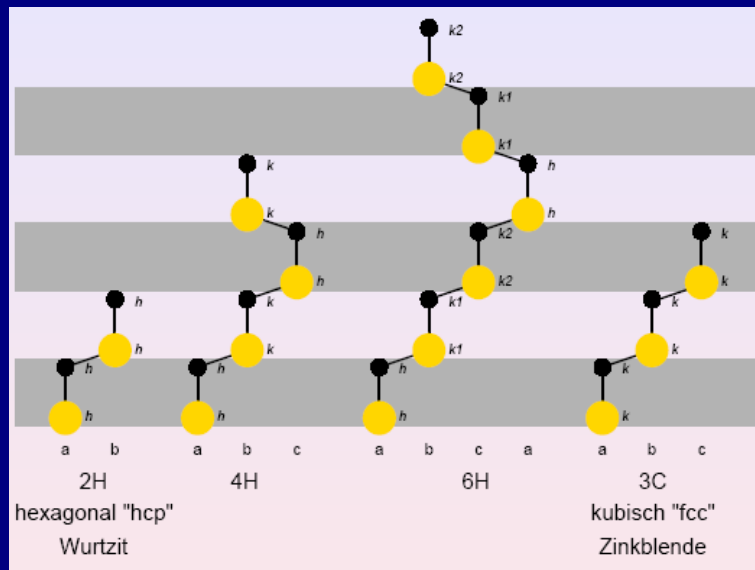
- pseudopotentials

On SiC: properties

On SiC: properties

Semiconductor:

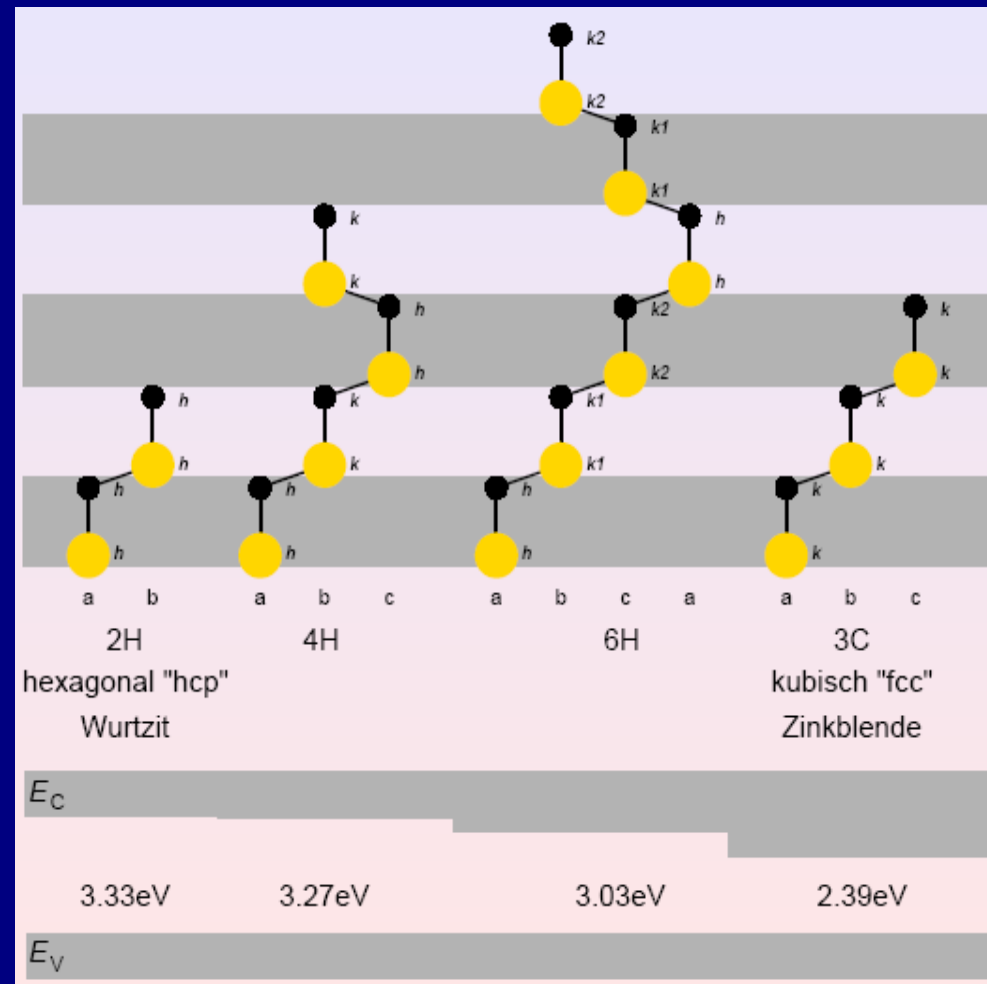
- polytypism



On SiC: properties

Semiconductor:

- polytypism

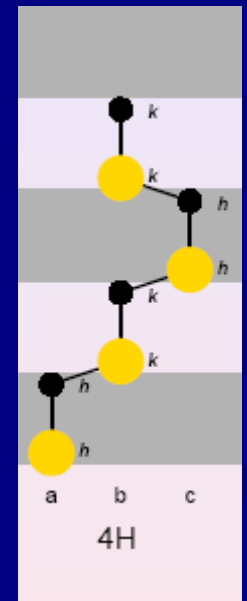
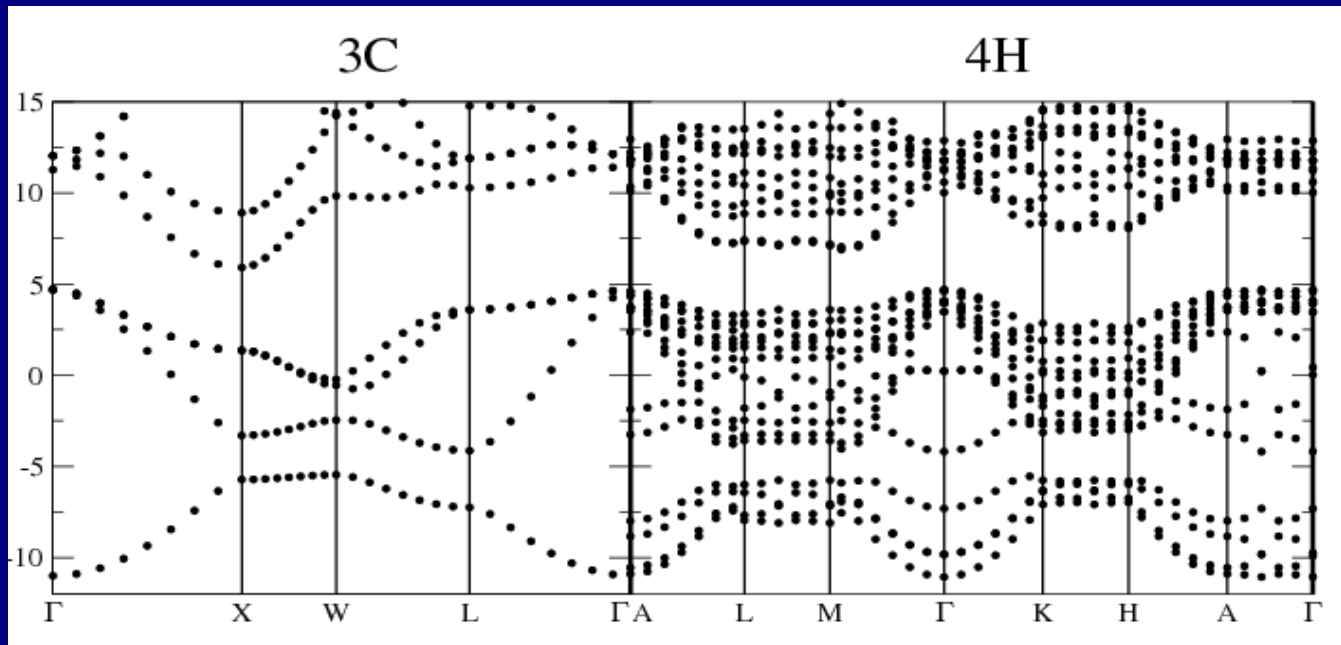
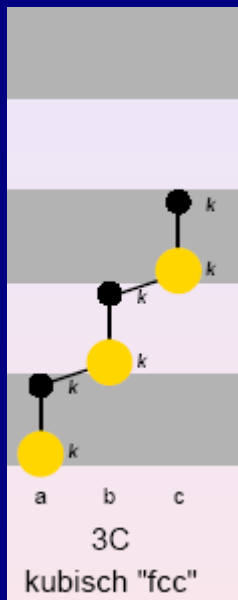


- wide band gap

On SiC: properties

Semiconductor:

- Band structure



On SiC: properties

Semiconductor:

- band gap ~ 3 eV
- high electron saturation velocity
- high thermal, mechanical and chemical stability

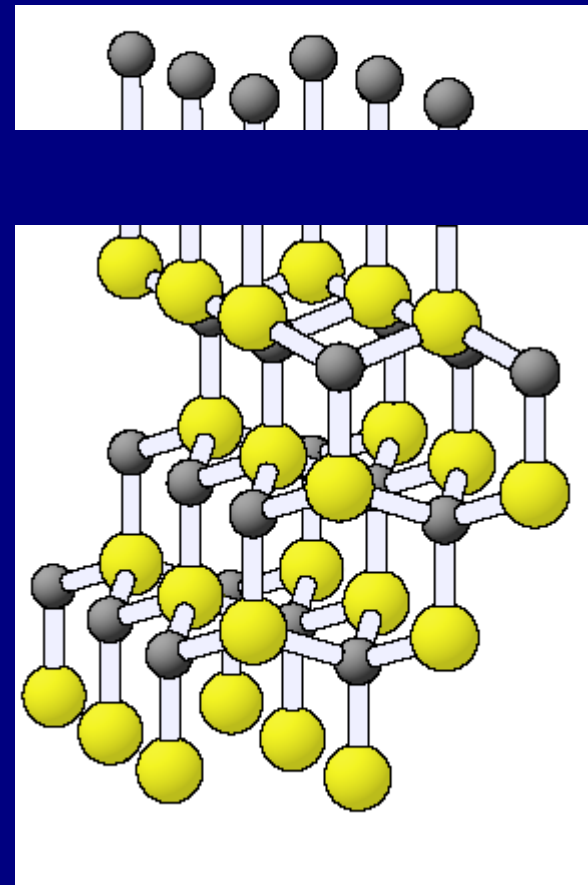
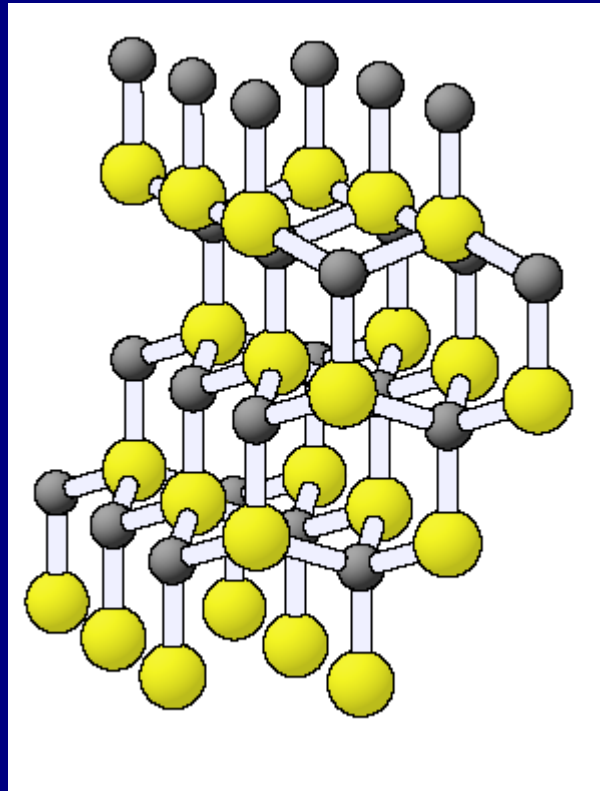


- high-temperature,
 - high-frequency,
 - and high-power
- Semiconductor devices

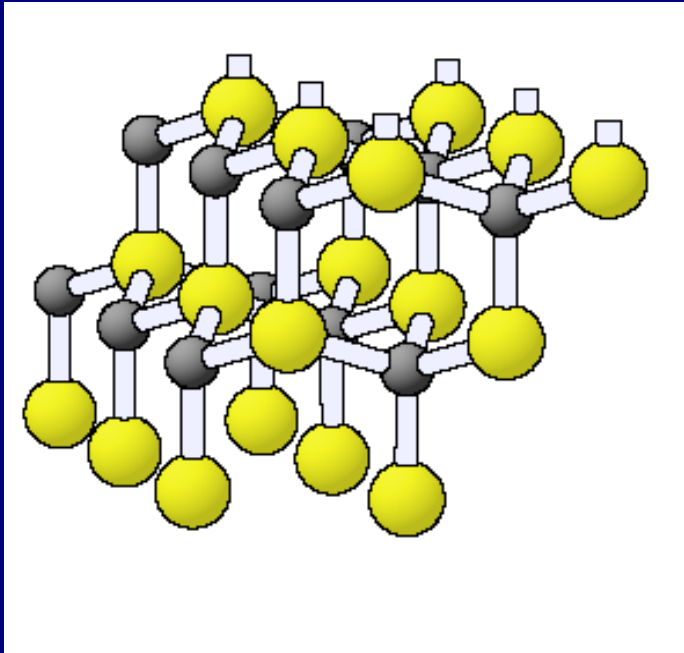
On SiC: surface reconstructions

rearrangement of atoms at a surface

On SiC: surface reconstructions

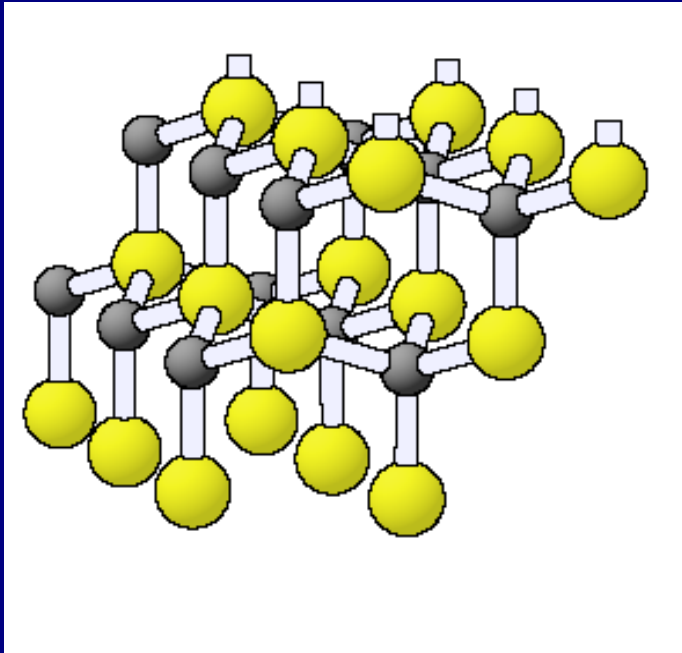


On SiC: surface reconstructions



unreconstructed SiC (0001)

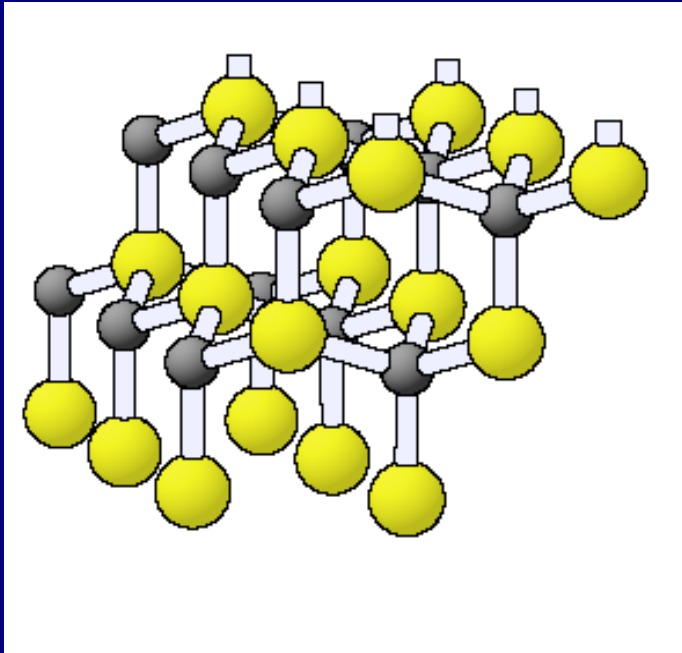
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What happens at the surface?

On SiC: surface reconstructions

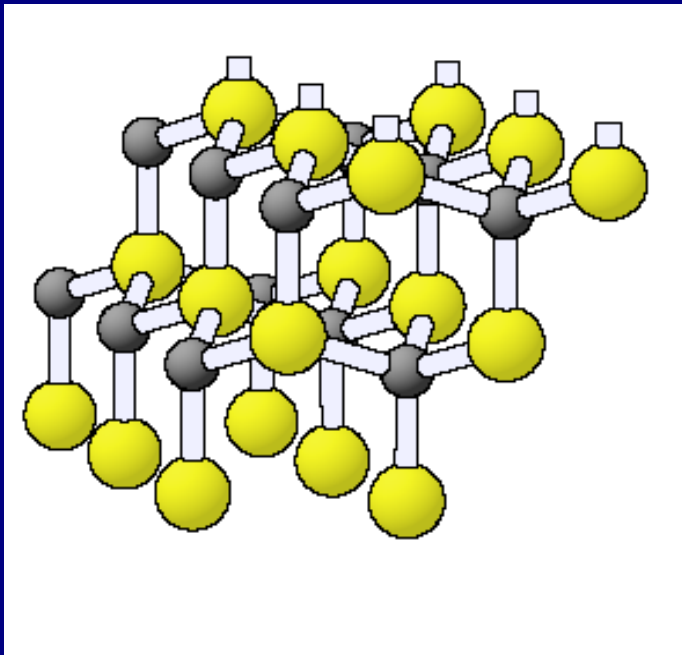


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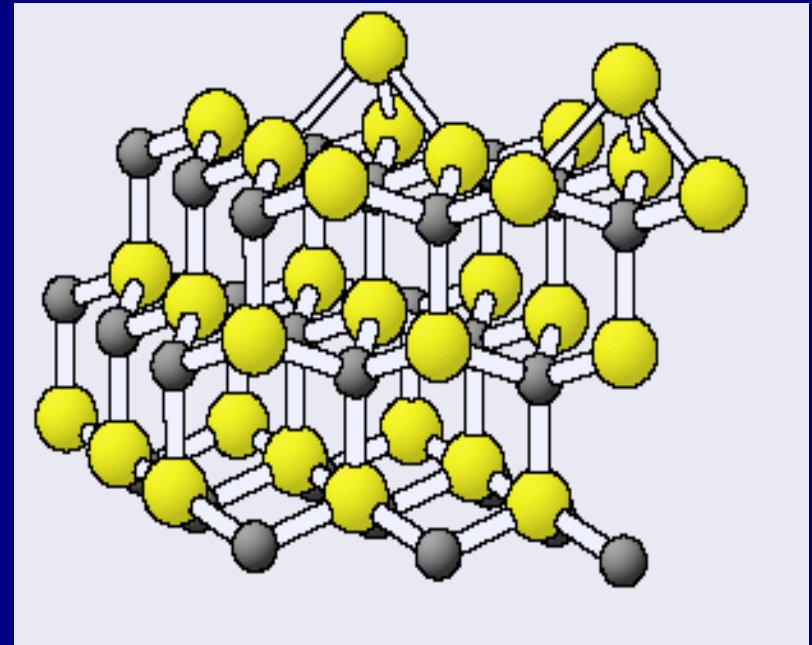
What happens at the surface?

Interaction of the dangling
bonds: bond saturation

On SiC: surface reconstructions



unreconstructed SiC (0001)

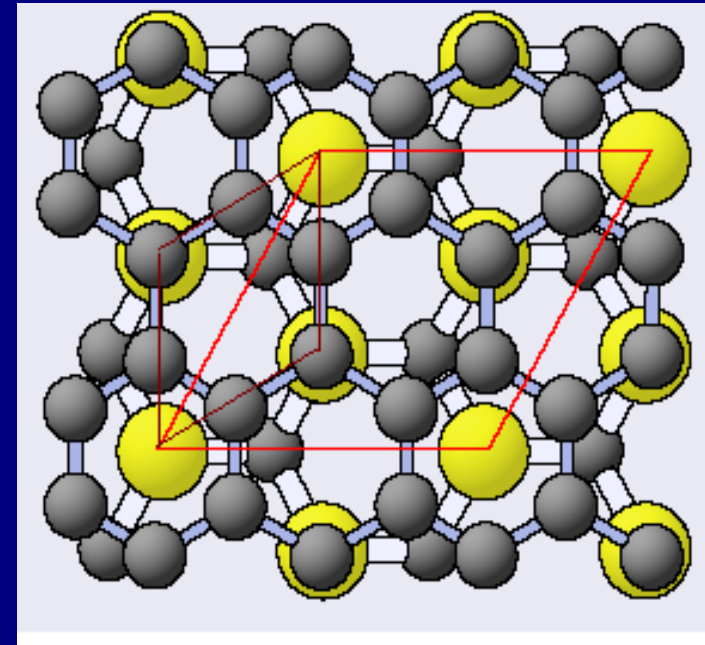
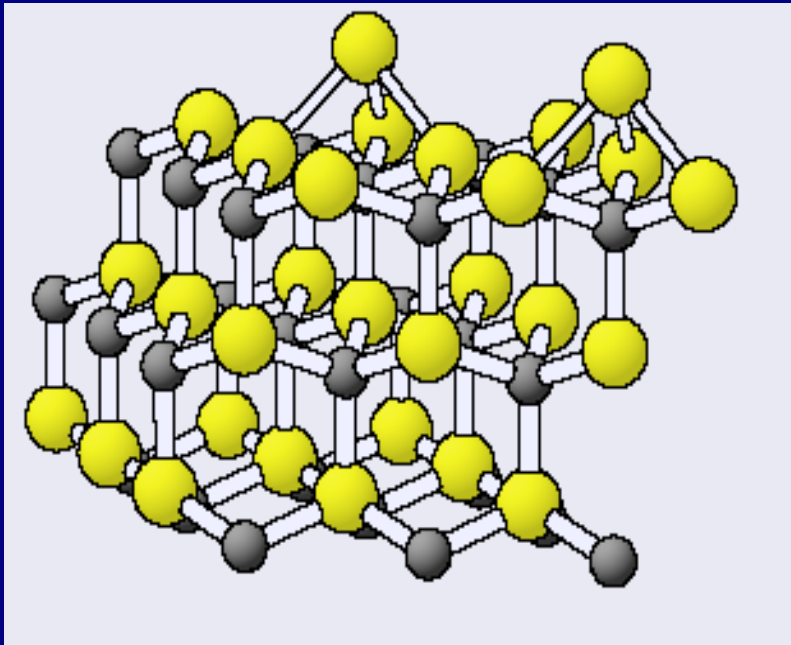


SiC(0001)- $\sqrt{3} \times \sqrt{3}R30^\circ$

reconstructed SiC:

- silicon-rich with Si adatoms
- 30° rotated unit cell

On SiC: reconstructions

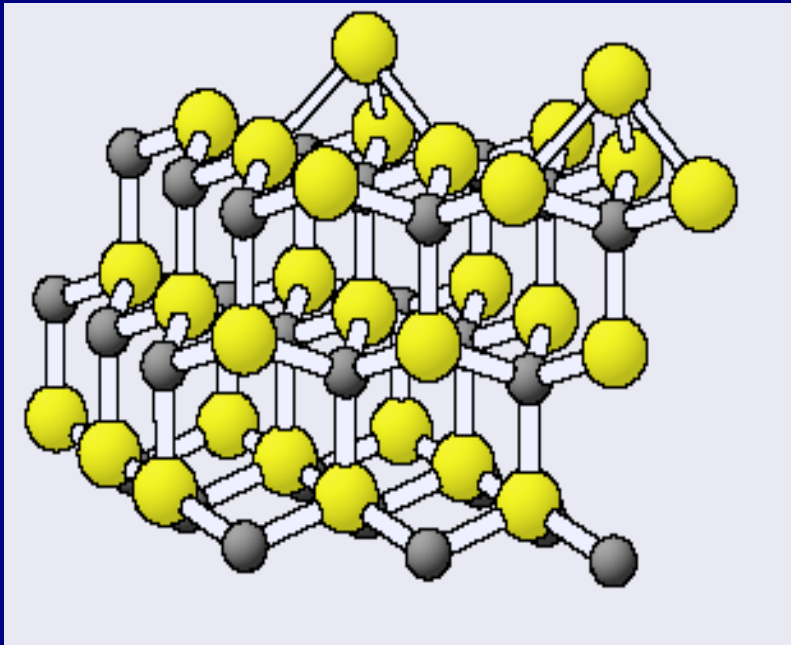


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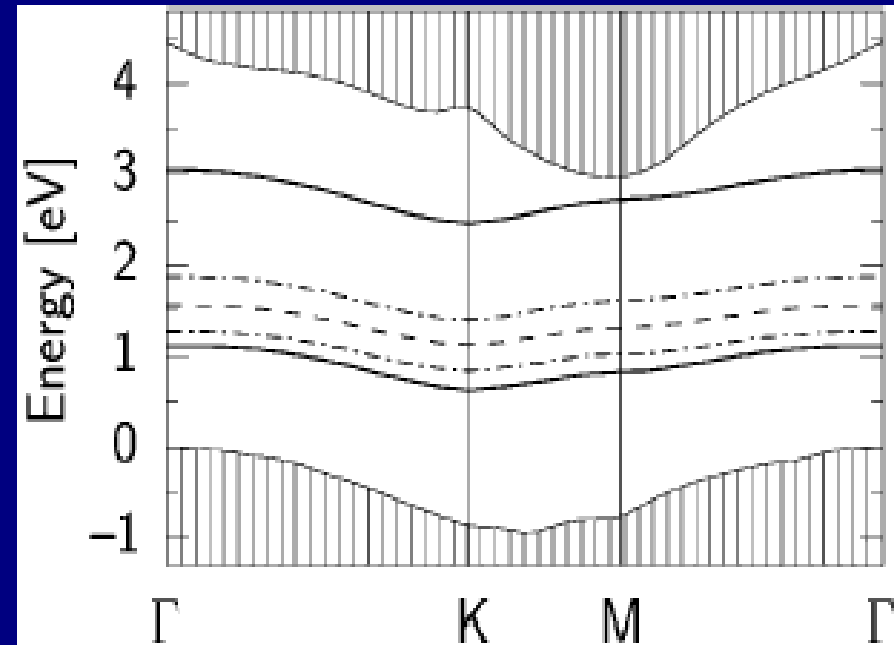
On SiC: reconstructions



$\text{SiC}(0001)-\sqrt{3} \times \sqrt{3}R30^\circ$

reconstructed SiC:

- silicon-rich with Si adatoms
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Band structure

On SiC: surface reconstructions

Hubbard-Mott system
necessary prior conditions:

- low interaction between neighbour orbitals
- strong self-interaction (Hubbard parameter U)

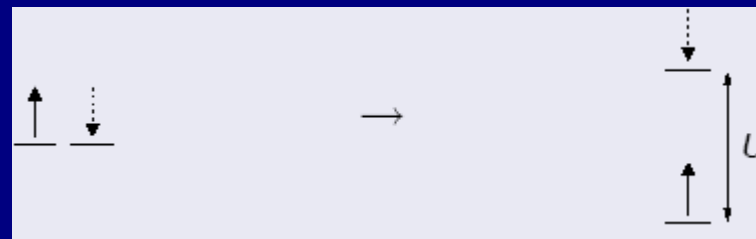
On SiC: surface reconstructions

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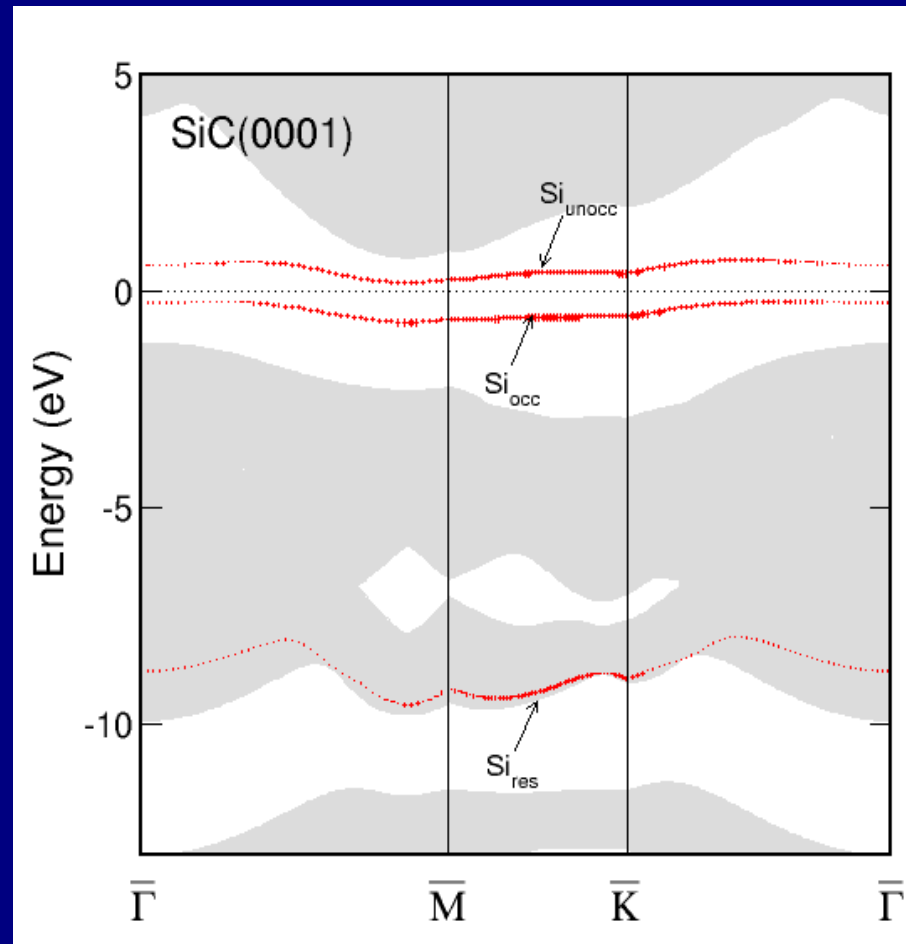
Effects on the band structure:

$$\epsilon_{1,2}(\mathbf{k}) \rightarrow \begin{aligned} \epsilon_1(\mathbf{k}) &= \epsilon_0 + \epsilon(\mathbf{k}) \\ \epsilon_2(\mathbf{k}) &= \epsilon_0 + \epsilon(\mathbf{k}) + U \end{aligned}$$



On SiC: surface reconstructions

Band structure of 1 x 1 SiC:

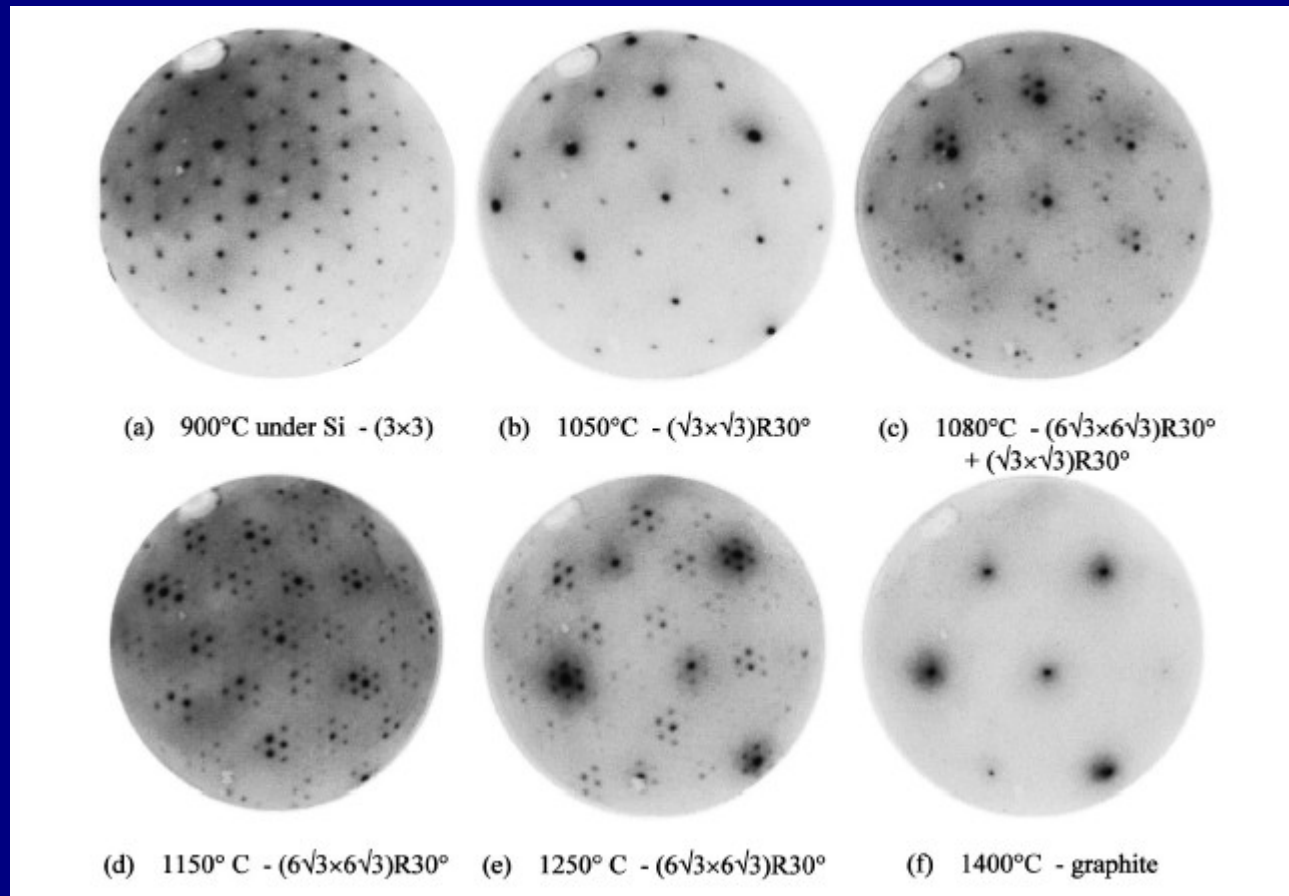


Production of SiC/Graphene

Annealing at elevated temperatures under vacuum

Production of SiC/Graphene

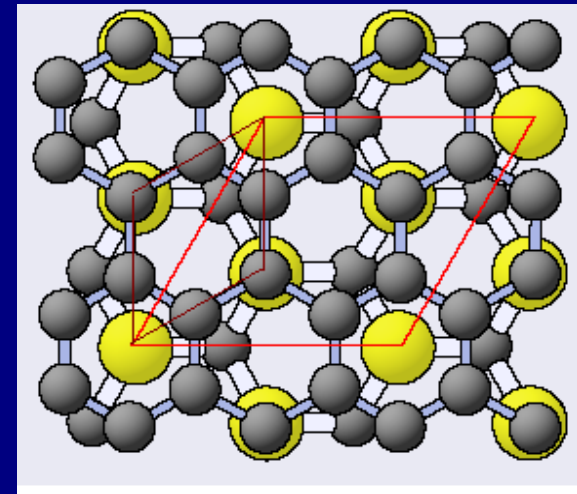
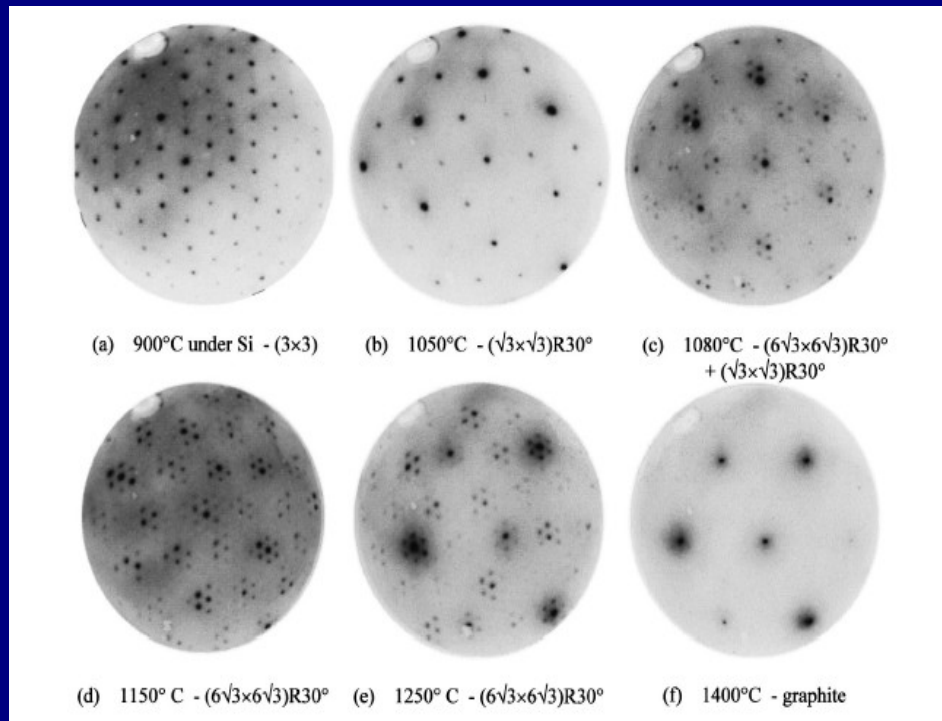
Annealing at elevated temperatures under vacuum



LEED patterns from $6H$ -SiC (0001)

Production of SiC/Graphene

Annealing at elevated temperatures under vacuum

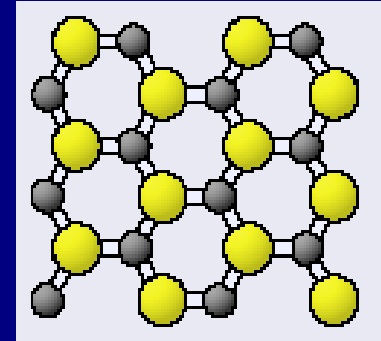


LEED patterns from *6H*-SiC (0001)

(b) $\sqrt{3} \times \sqrt{3}R30^\circ$

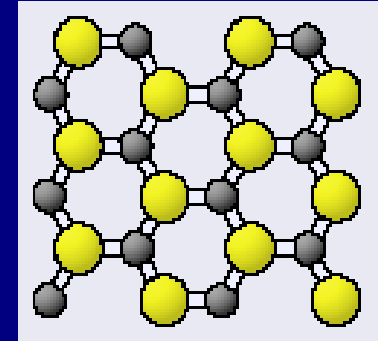
model interface

Substrate:
unreconstructed 1×1 -6H-SiC(0001)

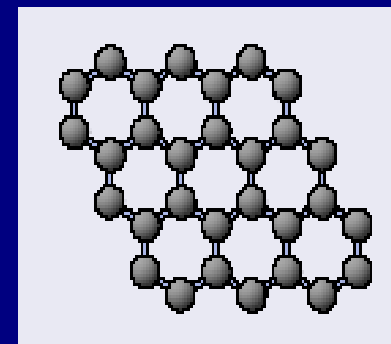


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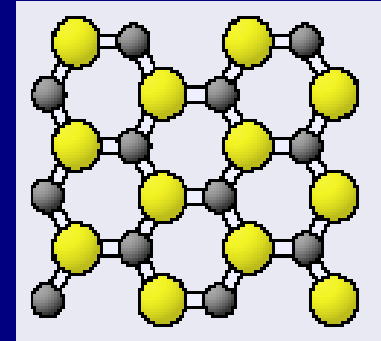


Graphene layer rotated by 30 and stretched by 8%



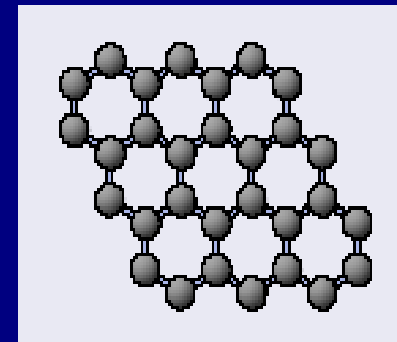
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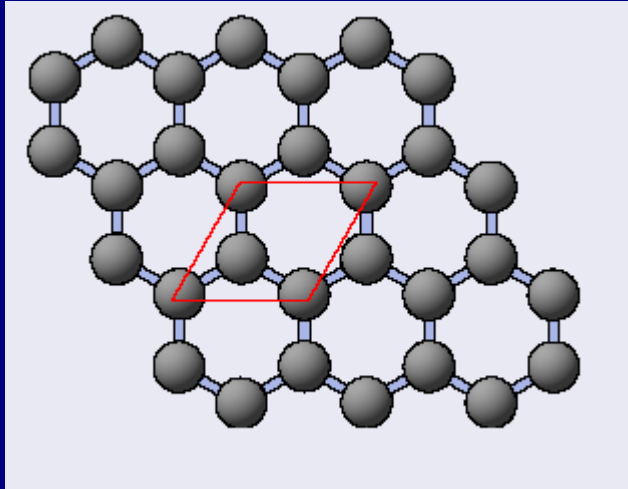


Graphene layer rotated by 30° and stretched by 8%

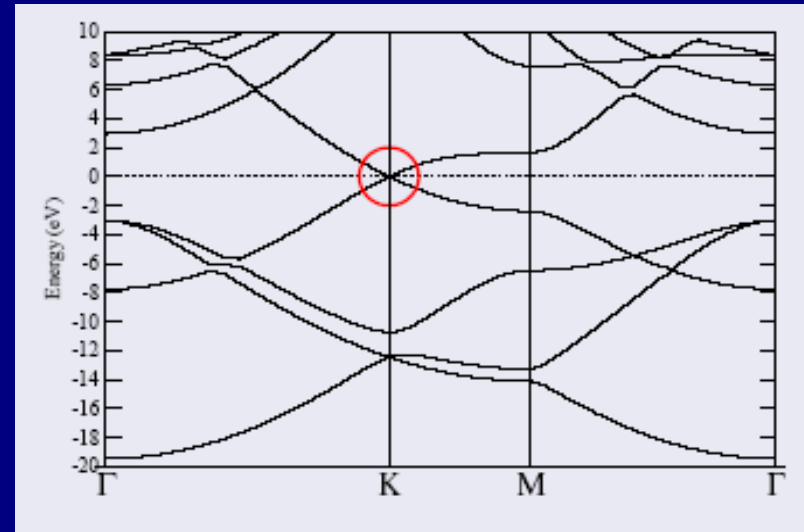
- stretch reduces total bandwidth ($19.1\text{eV} \rightarrow 17.3\text{eV}$)
- electronic spectrum close to Fermi energy unchanged
- elastic energy 0.8eV per graphene unit cell



Graphene



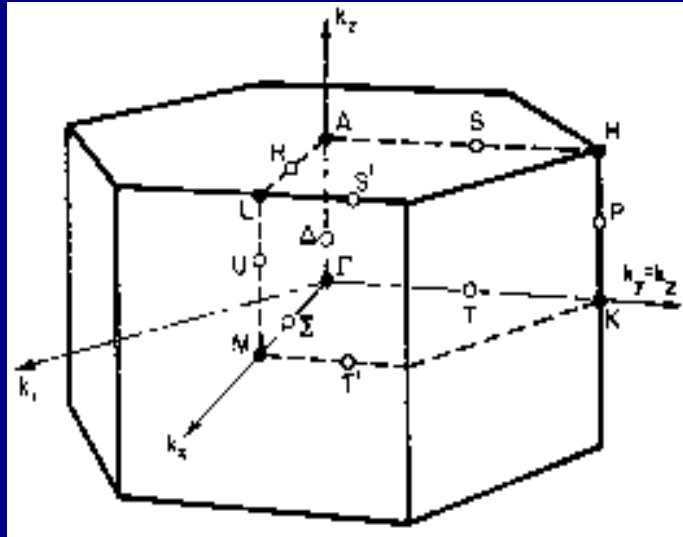
Atomic structure



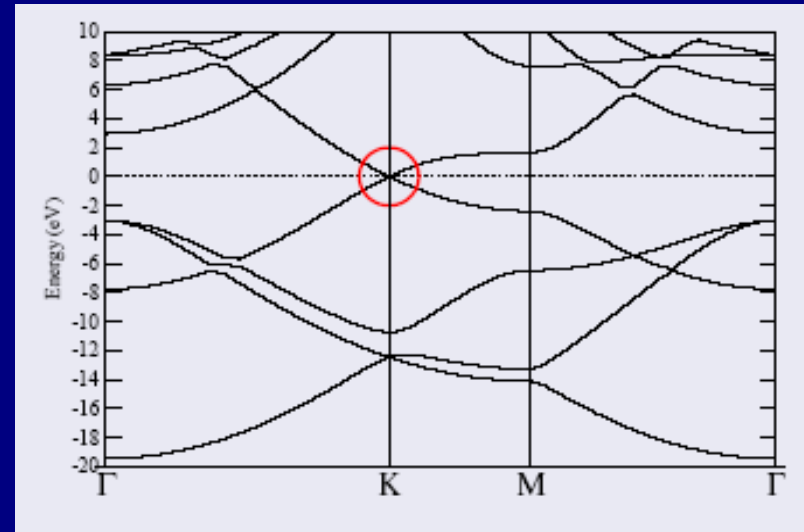
Band Structure:

- conic point at \bar{K}
- semi-metal

Graphene



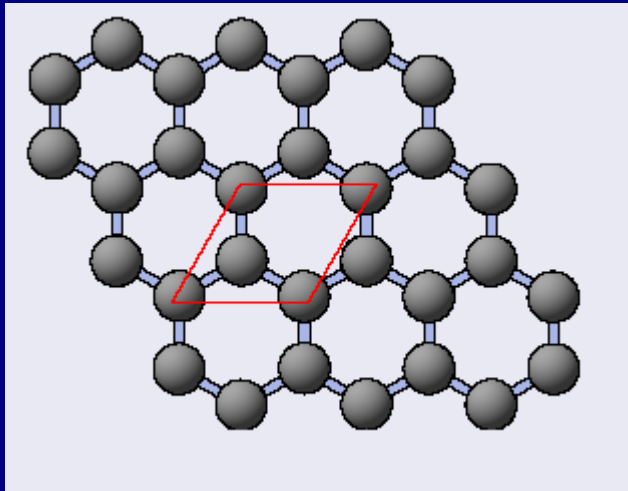
Brillouinzone



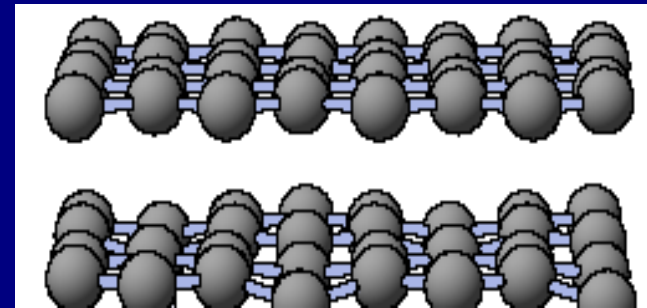
Band Structure:

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Graphene

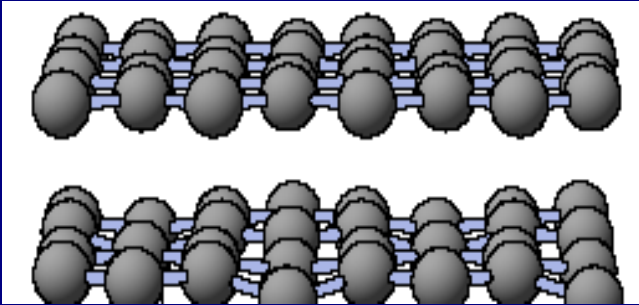


Atomic structure

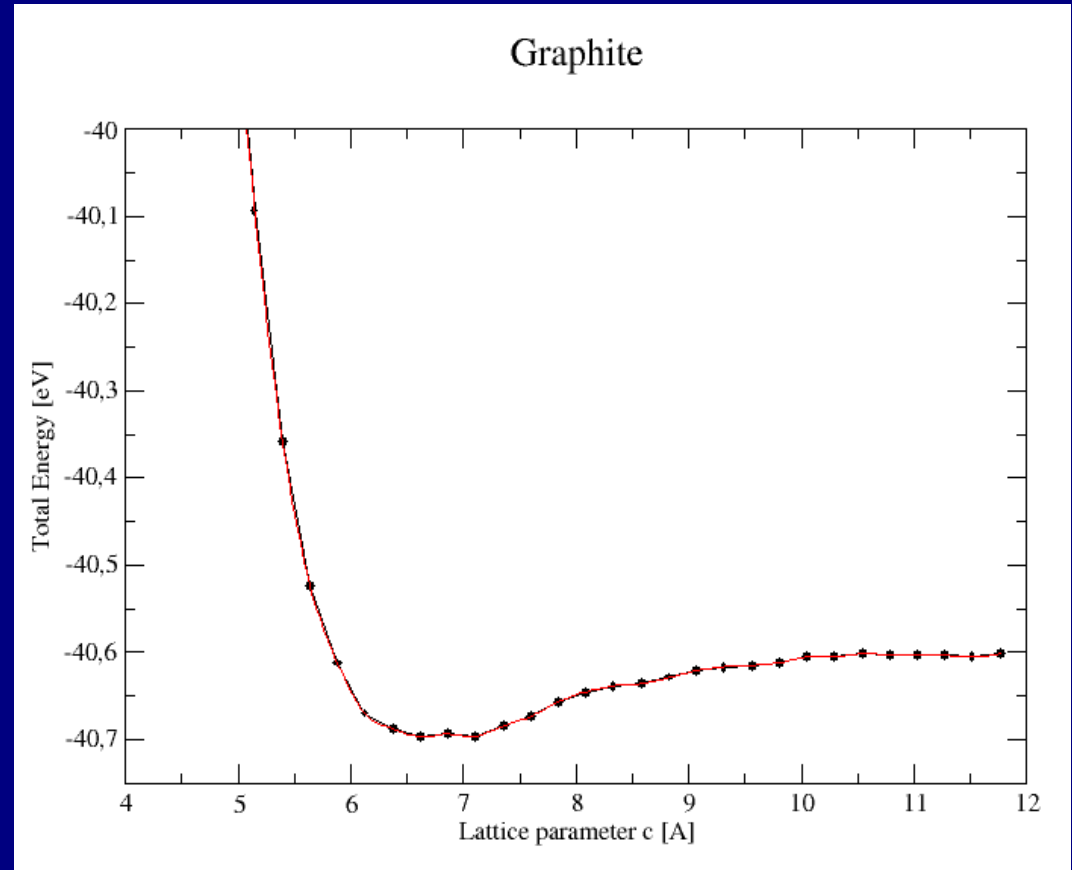


graphene layers bound by
van der Waals forces

Graphene



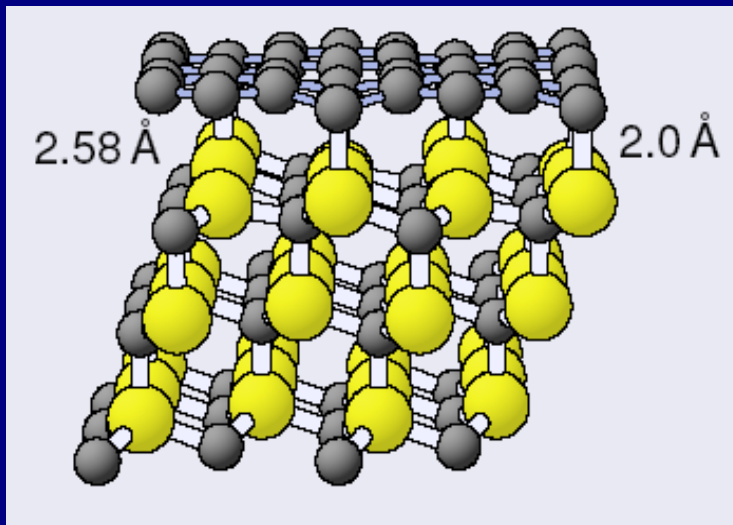
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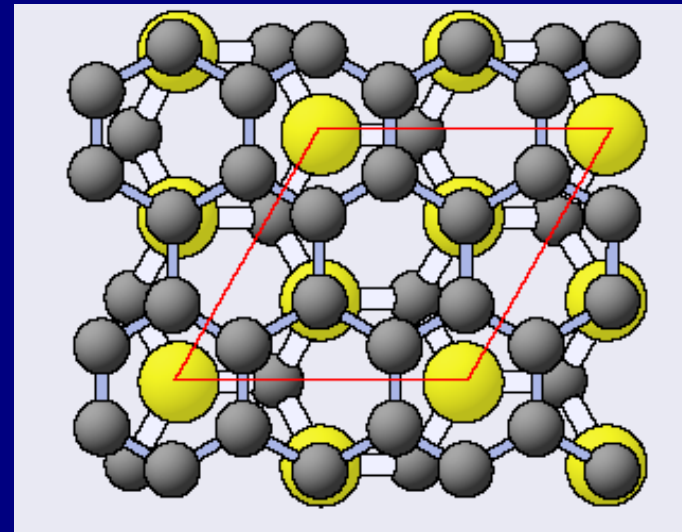
Results of the calculations

Results of the calculations

SiC(0001)/ Graphene:



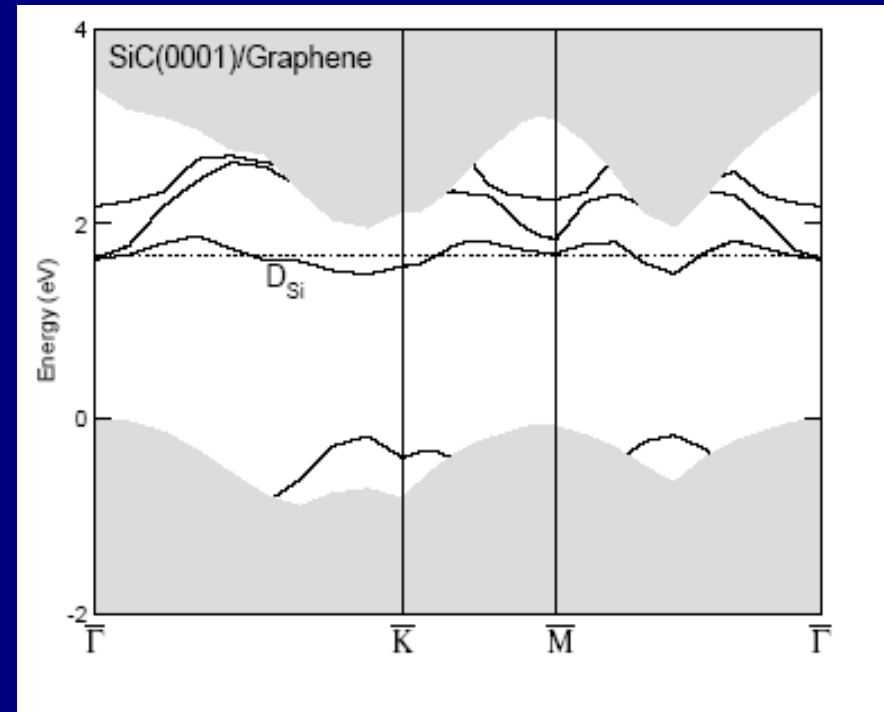
Graphene on 1×1 -SiC(0001)
Side view



Graphene on 1×1 -SiC(0001)
Top view

Results of the calculations

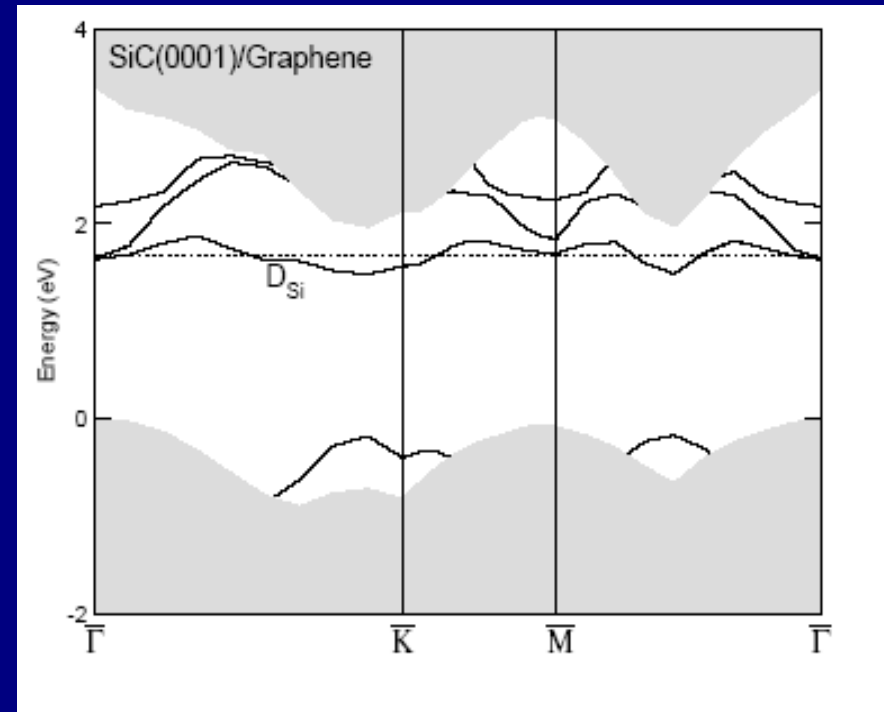
SiC(0001)/ Graphene:
Band structure:



Results of the calculations

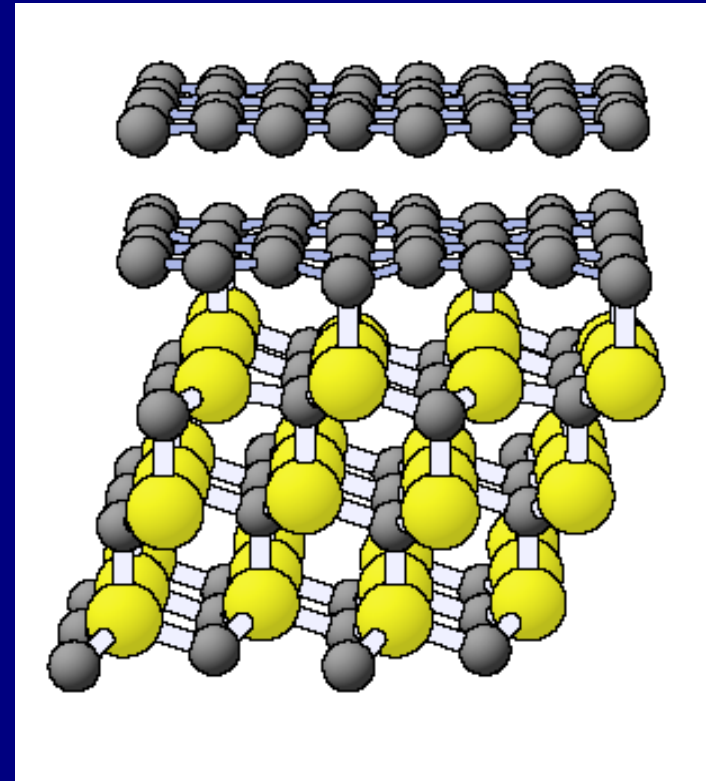
SiC(0001)/ Graphene:
Band structure:

- D_{Si} : interface state
 - metallic
 - mixture of dangling bond and graphene
- Fermi-Level pinned:
→ strong band bending



Results of the calculations

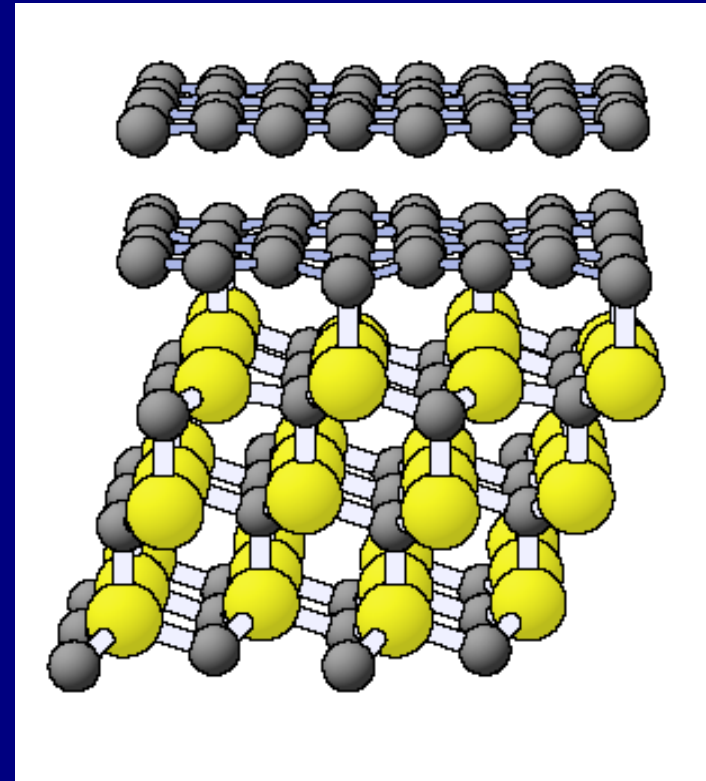
SiC(0001)/2 layers Graphene:



Results of the calculations

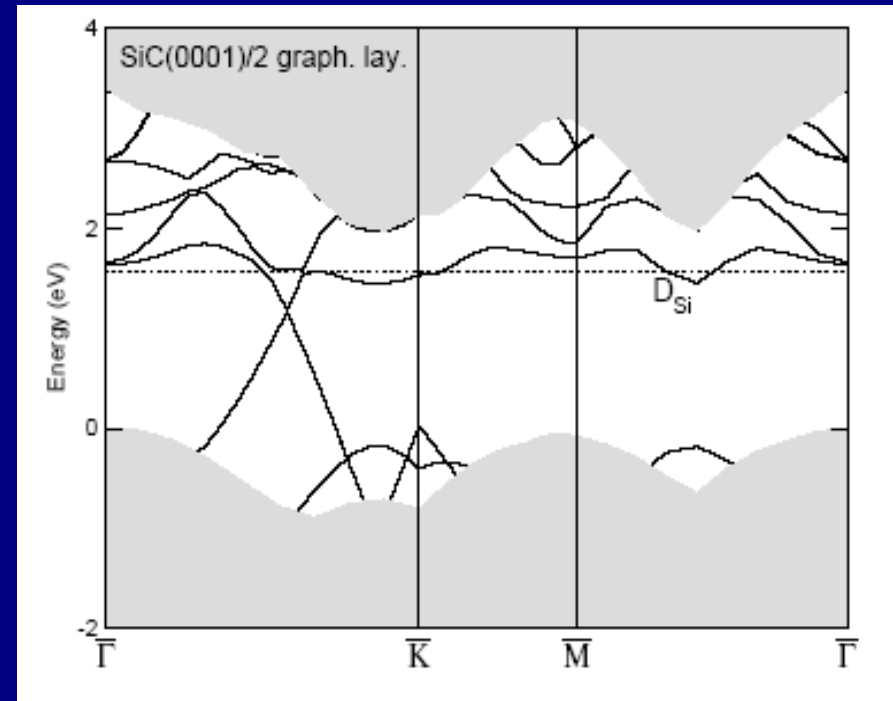
SiC(0001)/2 layers Graphene:

- 1st layer: covalently bonded
- 2nd layer: only van der Waals forces



Results of the calculations

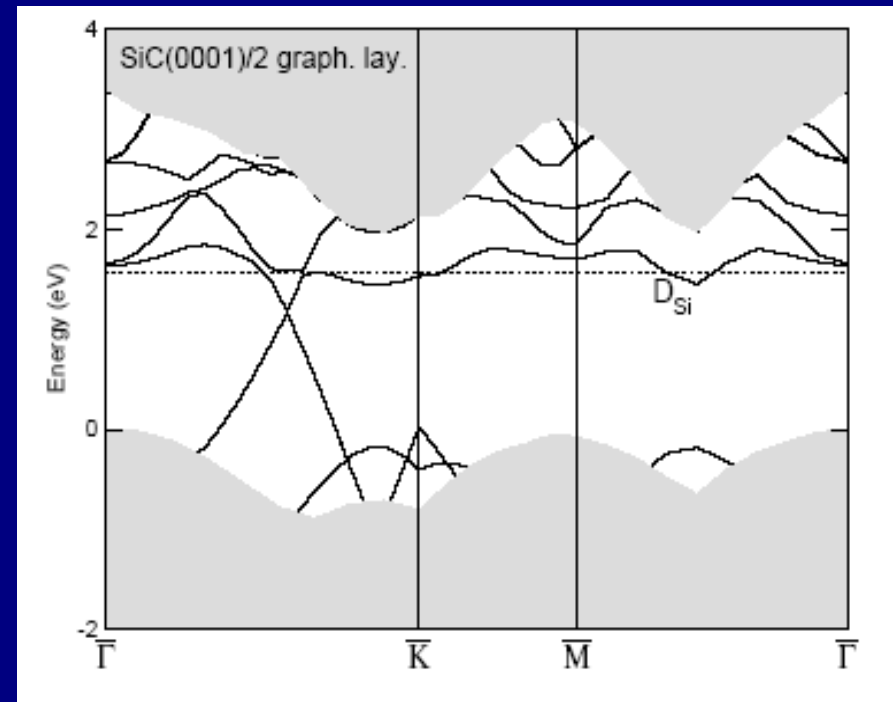
SiC(0001)/2 layers Graphene:
Band structure:



Results of the calculations

SiC(0001)/2 layers Graphene:
Band structure:

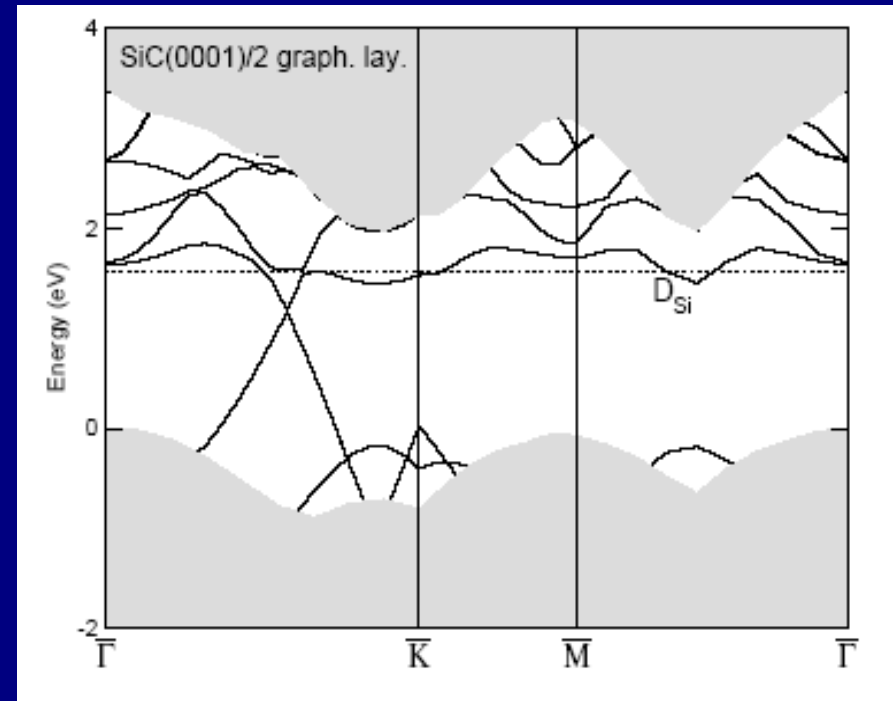
- Fermi-Level still pinned
→ charge flow to graphene
- Conic point appears below E_F
- further graphitic states



Results of the calculations

SiC(0001)/2 layers Graphene:
Band structure:

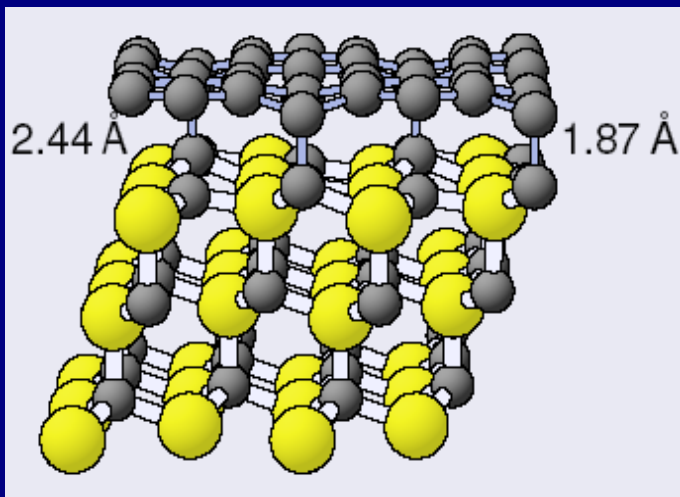
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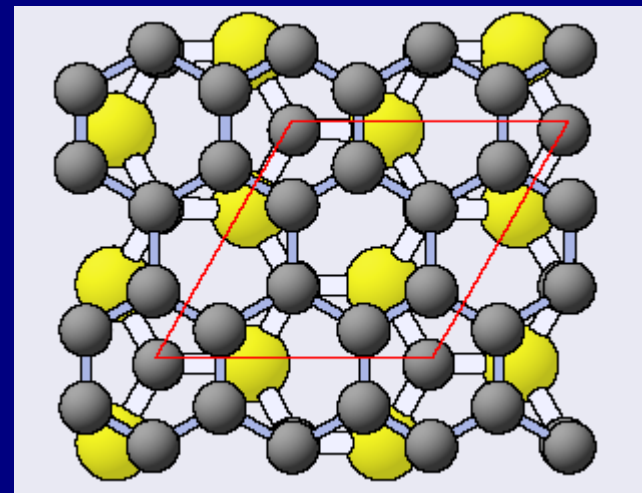
still metallic interface,
no splitting of the interface state D_{Si}

Results of the calculations

Graphene on 1×1 -SiC(000-1):



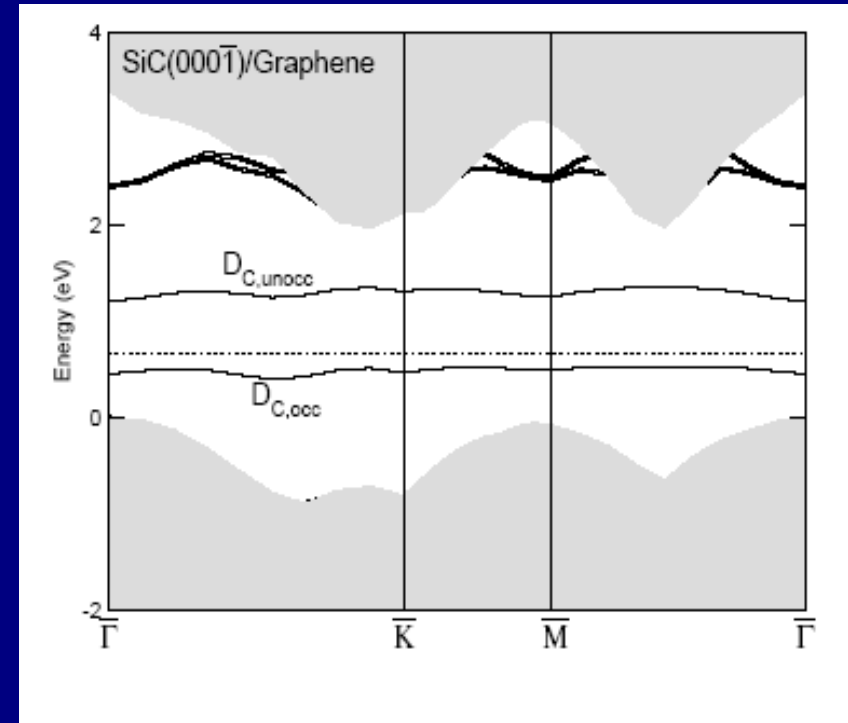
Graphene on 1×1 -SiC(000-1)
Side view



Graphene on 1×1 -SiC(000-1)
Top view

Results of the calculations

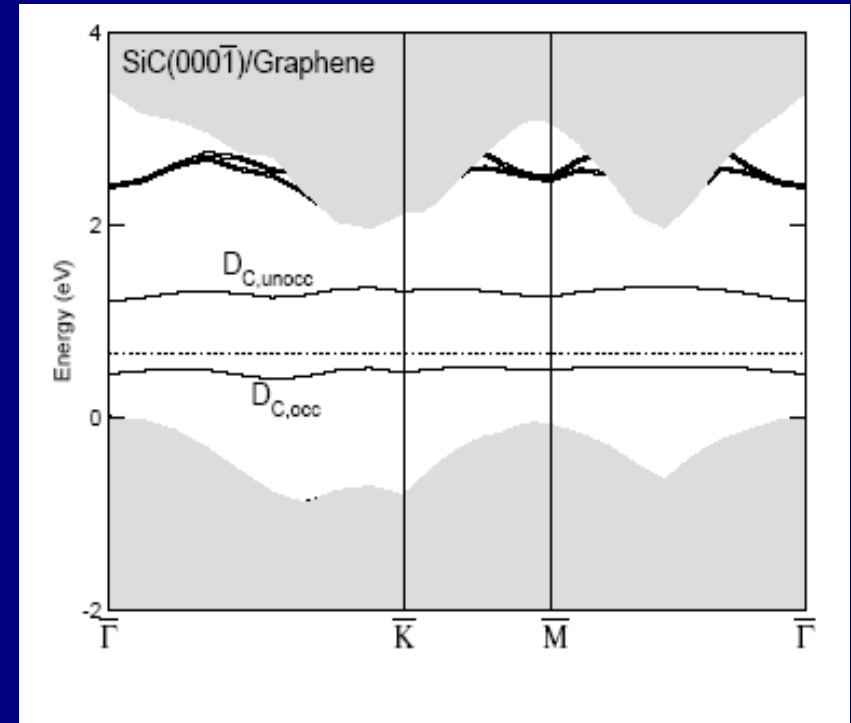
Graphene on 1×1 -SiC(000-1):
Band structure:



Results of the calculations

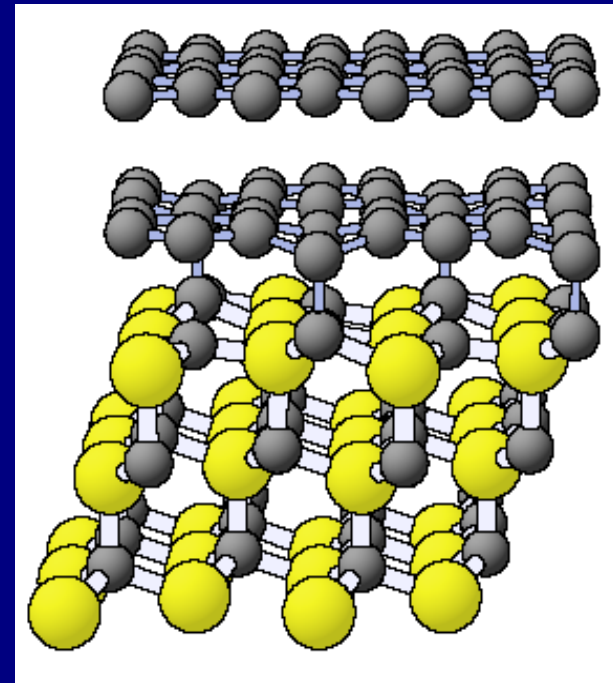
Graphene on 1×1 -SiC(000-1):
Band structure:

- C-dangling bond does not interact with the graphene layer
- D_C splits (selfinteraction)
→ semiconducting interface



Results of the calculations

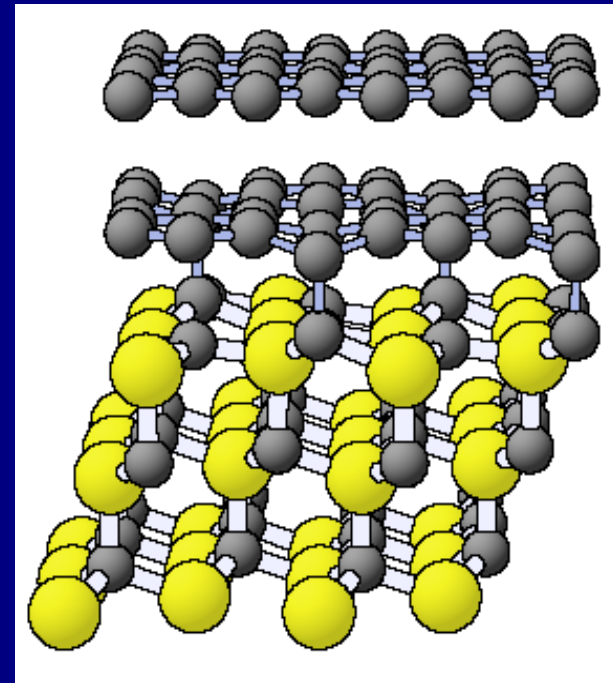
SiC(000-1)/2 layers Graphene:



Results of the calculations

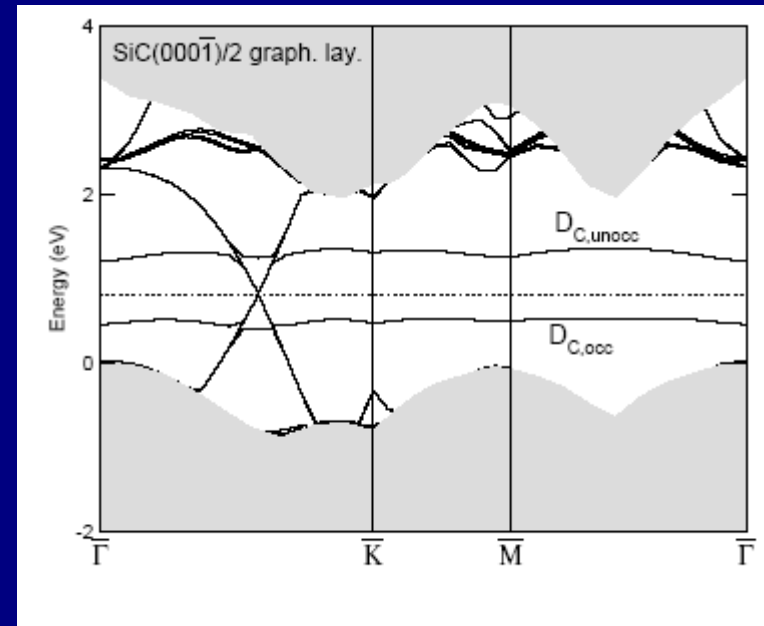
SiC(000-1)/2 layers Graphene:

- 1st layer: covalently bonded
- 2nd layer: weak bonded



Results of the calculations

SiC(000-1)/2 layers Graphene:
Band structure:

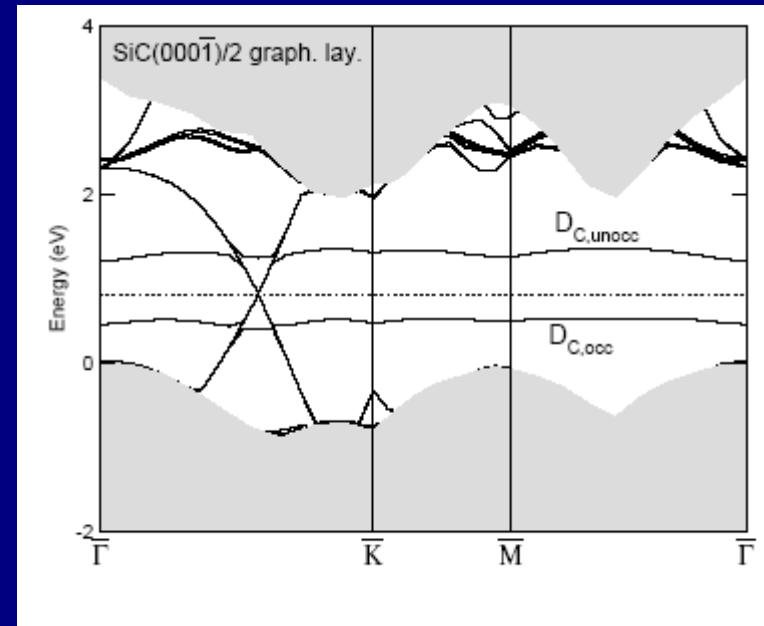


Results of the calculations

SiC(000 $\bar{1}$)/2 layers Graphene:
Band structure:

- conic point
- Fermi-Level determined by graphene

→ semimetallic behaviour

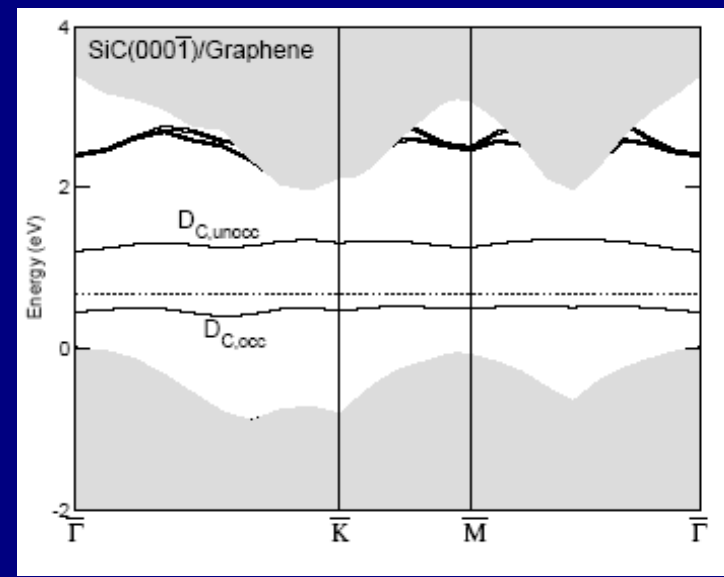
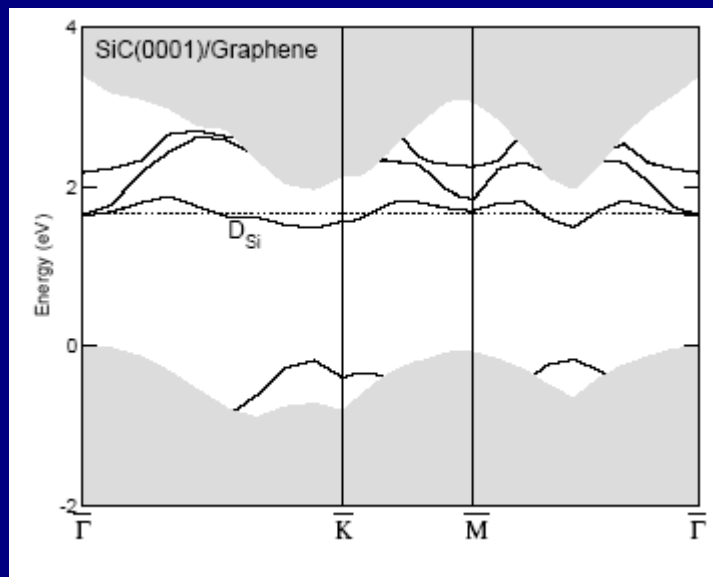


Results of the calculations

Comparison of both sides: SiC(0001)/Graphene and
SiC(000-1)/Graphene

Results of the calculations

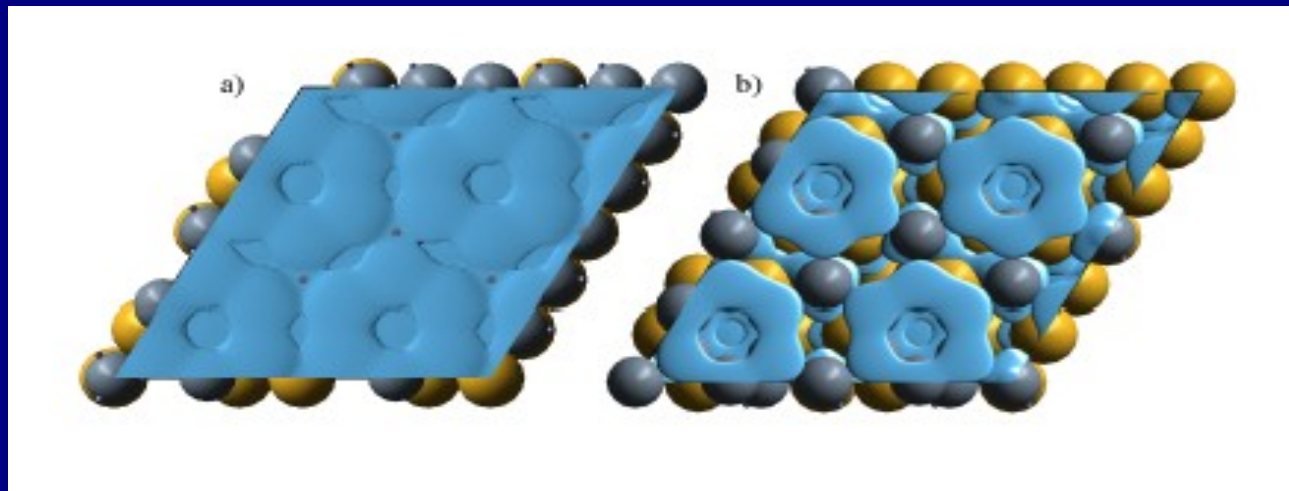
Comparison of both sides: SiC(0001)/Graphene and SiC(000-1)/Graphene
Band structures:



Results of the calculations

Comparison of both sides: SiC(0001)/Graphene and
SiC(000-1)/Graphene

Charge density of the interface states at Fermi energy:



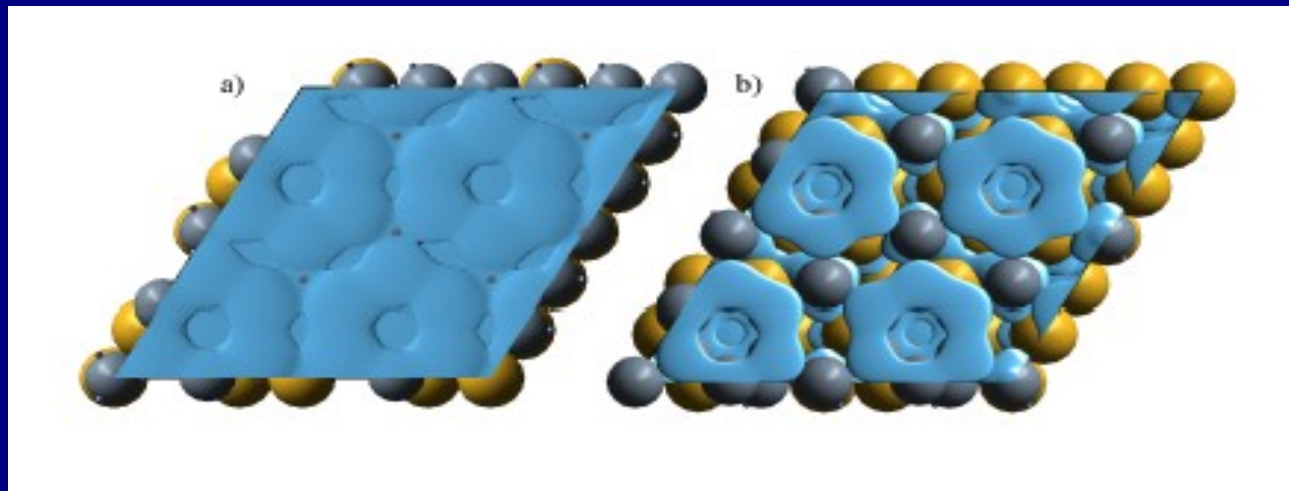
a) SiC(0001)

b) SiC(000-1)

Results of the calculations

Comparison of both sides: SiC(0001)/Graphene and SiC(000-1)/Graphene

Charge density of the interface states at Fermi energy:



a) SiC(0001)

b) SiC(000-1)

localisation favors spin polarization → splitting of the gap state at b)

Outlook

Outlook

What is still to study:

- Microscopic structure of the interface reconstructions
- Differences between the sides in more detail
(Experiments on the SiC(000-1) side)

THE END